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AMENDED CLAIMS

[received by the International Bureau on 19 November 2004 (19.11.04); claim 31 deleted; claim 39 new; original claim 34 replaced by amended claim 34; remaining claims unchanged]

- 23. The process of Claim 22 wherein R² is ortho, para-difluorophenyl.
- 24. The process of Claim 1 wherein the compound of structural formula (I) is isolated by forming a zwitterion of the trans pyrrolidine acid of structural formula (I)

wherein R1 and R2 are as defined above; recrystallizing the zwitterion from a solvent; and isolating the resulting product.

- 10 25. The process of Claim 24 wherein the zwitterion of the pyrrolidine acid of formula
 (I) is formed at the isoelectric pH using an acid.
 - 26. The process of Claim 25 wherein the acid is selected from sulfuric acid or hydrochloric acid.
 - 27. The process of Claim 26 wherein the acid is sulfuric acid.
 - 28. The process of Claim 24 wherein the zwitterion of the pyrrolidine acid of formula

 (I) is recrystallized from a solvent.
 - 29. The process of Claim 28 wherein the solvent is selected from the group consisting of ethanol, isopropyl alcohol, methyl *tert*-butyl ether or a mixture thereof.
- 30. The process of Claim 29 wherein the solvent is a mixture of 1:3 isopropyl alcohol:methyl *tert*-butyl ether.
 - 32. The compound 2

or a zwitterion or salt thereof.

33. The compound 3

5 or a zwitterion or a salt thereof.

34. A process for the preparation of compounds of structural formula (I):

wherein

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RI is selected from the group consisting of

- (1) hydrogen,
- (2) amidino,
- (3) C₁₋₄ alkyliminoyl,
- ...15 (4) C₁₋₁₀ alkyl,
 - (5) $-(CH_2)_n-C_3-7$ cycloalkyl.
 - (6) $-(CH_2)_n$ -phenyl.
 - (7) -(CH2)_n-naphthyl, and
 - (8) -(CH2)n-heteroaryl,

in which phenyl, naphthyl, and heteroaryl are unsubstituted or substituted with one to three groups independently selected from R³; and alkyl, cycloalkyl, and (CH₂)_n are unsubstituted or substituted with one to three groups independently selected from R³ and oxo;

R2 is selected from the group consisting of

- 25 (1) C₁₋₄ alkyl,
 - (2) $-(CH_2)_n$ -cycloalkyl,
 - (3) -(CH2)n-heterocycloalkyl.

	(4)	-(CH ₂) _n -phenyl,
	(5)	-(CH2)n-naphthyl, and
	(6)	-(CH2)n-heteroaryl wherein heteroaryl is selected from the group consisting of
		(1) pyridinyl,
5		(2) furyl,
		(3) thienyl,
		(4) pyπolyl,
		(5) oxazolyl,
		(6) thiazolyl,
10		(7) imidazolyl,
		(8) pyrazolyl,
		(9) isoxazolyl,
		(10) isothiazolyl,
		(11) pyrimidinyl,
15		(12) pyrazinyl,
		(13) pyridazinyl,
		(14) quinolyl,
		(15) isoquinolyl,
		(16) benzimidazolyl,
20		(17) benzofuryl,
		(18) benzothienyl,
		(19) indolyl,
		(20) benzthiazolyl, and
		(21) benzoxazolyl;
25		l. phenyl. naphthyl, heteroaryl, and (CH2)n are unsubstituted or substituted with one to three
	groups indep	endently selected from R ³ ;
	each R3 is in	dependently selected from the group consisting of
	(1)	C ₁₋₆ alkyl,
30	(2)	-(CH ₂) _n -phenyl,
	(3)	-(CH ₂) _n -naphthyl,
	(4)	-(CH ₂) _n -heteroaryl,
	(5)	-(CH ₂) _n -heterocycloalkyl,
	(6)	-(CH ₂) _n C ₃ -7 cycloalkyl,
35	(7)	halogen.

- (8) OR⁴,
- (9) $-(CH_2)_nN(R^4)_2$,
- (10) NO₂.
- (11) $-(CH_2)_nNR^4SO_2R^4$,
- (12) $-(CH_2)_n SO_2 N(R^4)_2$.
- (13) $-(CH_2)_nS(O)_pR^4$,
- (14) CF₃,
- (15) CH2CF3,
- (16) OCF3, and
- 10 (17) OCH₂CF₃;

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in which heteroaryl is as defined above: alkyl, phenyl, naphthyl, heteroaryl, cycloalkyl, and heterocycloalkyl are unsubstituted or substituted with one to three substituents independently selected from halogen, hydroxy, oxo, C₁₋₄ alkyl, trifluoromethyl, and C₁₋₄ alkoxy; and wherein any methylene (CH₂) carbon atom in R³ is unsubstituted or substituted with one to two groups independently selected from halogen, hydroxy, and C₁₋₄ alkyl; or two substituents when on the same methylene (CH₂) group are taken together with the carbon atom to which they are attached to form a cyclopropyl group;

each R4 is independently selected from the group consisting of

- (1) hydrogen,
- (2) C₁₋₆ alkyl,
 - (3) $-(CH_2)_n$ -phenyl,
 - (4) -(CH₂)_n-heteroaryl,
 - (5) $-(CH_2)_n$ -naphthyl,
 - (6) -(CH2)n-heterocycloalkyl,
- (7) -(CH₂)_nC₃-7 cycloalkyl, and
 - (8) -(CH₂)_nC₃-7 bicycloalkyl;

wherein alkyl, phenyl, heteroaryl, heterocycloalkyl, and cycloalkyl are unsubstituted or substituted with one to three groups independently selected from halogen, C₁₋₄ alkyl, hydroxy, and C₁₋₄ alkoxy; or two R⁴ groups together with the atom to which they are attached form a 4- to 8-membered mono- or bicyclic ring system optionally containing an additional heteroatom selected from O, S, and NC₁₋₄ alkyl; and

n is 0, 1, 2, 3 or 4;

comprising the steps of:

(a) hydrolyzing a pyrrolidine compound of structural formula (X), wherein Y is -CN or -CO₂R⁵ and 35 R⁵ is C_{1.4} alkyl, and wherein R¹ and R² are as defined above,

with an aqueous base in a solvent; and

(b) isolating the resulting product.

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- 35. The process of Claim 34 wherein the pyrrolidine compound of formula (X) is hydrolyzed with a base selected from the group consisting of NaOH, LiOH and KOH.
 - 36. The process of Claim 35 wherein the base is aqueous NaOH.
- 37. The process of Claim 36 wherein R² is selected from the group of phenyl; ortho, para-difluorophenyl; and para-methoxyphenyl.
 - 38. The process of Claim 37 wherein R2 is ortho, para-difluorophenyl.
- 39. The process of Claim 34 wherein R1 is tert-butyl.

Statement Under Article 19(1)

Claim 34 of the international application has been amended to recite Y is -CN or - CO2R5 and R5 is C1-4 alkyl. New Claim 39 of the international application has been added to recite R1 is tert-butyl. The amendment and new claim are fully supported by the Applicant's description. The present amendment and new claim have no impact on the description and the drawings of the international application.